

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Nakamura, T.
Appl. No.	:	10/553,159
Filed	:	October 14, 2005
For	:	RESIN FOR UNDERCOATING MATERIAL, UNDERCOATING MATERIAL, LAMINATE, AND MULTILAYERED RESIST PATTERN FORMING METHOD
Examiner	:	Eoff, A.
Group Art Unit	:	1795

AMENDMENT AND RESPONSE TO OFFICE ACTION**Mail Stop Amendment**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **December 10, 2007**, please amend the above-captioned U.S. National Phase Application as follows:

Amendments to the Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 5 of this paper.